

IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A liquid crystal display device comprising:
transistors disposed at the intersections of gate lines and source lines;
pixel electrodes connected with the transistors;
opposite electrodes opposite to these pixel electrodes; and
liquid crystal held between said opposite electrodes and said pixel electrodes,
wherein said pixel electrodes comprise a first pixel electrode and a second pixel
electrode disposed in a layer above an insulating film which is itself disposed in a layer
above the first pixel electrode, and having a region that does not overlap with the first pixel
electrode, and
wherein the first pixel electrode and second pixel electrode are electrically connected,
the first pixel electrode applying a first electric field to the liquid crystal, and the second
pixel electrode applying a second electric field whose strength is different from the first
electric field to the liquid crystal, and
wherein a ratio of a first voltage applied to the first pixel electrode and a second
voltage applied to the second pixel electrode is 0.5:1.0 to 0.9:1.0.

Claim 2 (Previously Presented): The liquid crystal display device, according to
Claim 1, wherein the cumulative capacitance for stabilizing the pixel potential during the
holding period is formed between said second pixel electrode and a storage capacitance
electrode line or between the second pixel electrode and the preceding gate line adjacent
thereto.

Claim 3 (Original): The liquid crystal display device, according to Claim 1, wherein said first pixel electrode is disposed in the same layer as the gate line.

Claim 4 (Original): The liquid crystal display device, according to Claim 1, wherein an insulating film is disposed in the layer below said gate line, and said first pixel electrode is disposed in the layer below said insulating film.

Claim 5 (Previously Presented): The active matrix liquid crystal display device, according to Claim 1,

wherein a first gate insulating film is disposed in the layer above said gate line, said first pixel electrode is disposed in the layer above the first gate insulating film, a second gate insulating film is disposed in the layer above the first pixel electrode, an interlayer insulating film is disposed in the layer above the second gate insulating film, and said second pixel electrode is disposed in the layer above the interlayer insulating film.

Claim 6 (Original): The liquid crystal display device, according to Claim 1, wherein said first pixel electrode is disposed in the same layer as the drain lines of said transistors.

Claim 7 (Original): The liquid crystal display device, according to Claim 6, wherein said first pixel electrode is directly connected to the drain electrode of said transistors.

Claim 8 (Original): The liquid crystal display device, according to Claim 1, wherein said second pixel electrode comprises an opening in the central portion, and said insulating film and said liquid crystal are held between said first pixel electrode and opposite electrode in that opening.

Claim 9 (Currently Amended): A liquid crystal display device comprising:
transistors disposed at the intersections of gate lines and source lines;
pixel electrodes connected with the drain electrodes of the transistors;
opposite electrodes opposite to these pixel electrodes; and
liquid crystal held between said opposite electrodes and said pixel electrodes,
wherein said pixel electrodes comprise a first pixel electrode and a second pixel
electrode disposed in a layer above an insulating layer which is itself disposed in a layer
above the first pixel electrode, and having a region that does not overlap with the first pixel
electrode, and

wherein the first pixel electrode and second pixel electrode are electrically connected
with said drain electrode, the first pixel electrode applying first electric field to the liquid
crystal, and the second pixel electrode applying a second electric field whose strength is
different from the first electric field to the liquid crystal, and

wherein a ratio of a first voltage applied to the first pixel electrode and a second
voltage applied to the second pixel electrode is 0.5:1.0 to 0.9:1.0.

Claim 10 (Canceled).

Claim 11 (Original): The liquid crystal display device, according to Claim 1 or 9,
wherein the thickness of said insulating layer is 500 nm or greater.

Claim 12 (Original): The liquid crystal display device, according to Claim 1 or 9,
wherein said pixel electrode is a transparent electrode.

Claim 13 (Canceled).

Claim 14 (Previously Presented): A liquid crystal display device, having liquid crystal held between a pair of substrates and including a plurality of pixels each having switching device, said liquid crystal display device further comprising:

means for applying spatially different voltages to the liquid crystal in one of the plurality of pixels;

an alignment layer disposed on the surface of each substrate in contact with the liquid crystal, for orienting said liquid crystal;

a polarizing plate disposed on the surface opposite to the surface of each of said substrates in contact with the liquid crystal; and

an optical compensating film disposed between said polarizing plate and said substrate having stabilized the orientation state of discotic liquid crystal.

Claim 15 (Original): The liquid crystal display device, according to Claim 14, wherein the product of the birefringence Δn of said liquid crystal and the thickness d of the liquid crystal layer satisfies the relationship of $0.30 \mu\text{m} \leq \Delta n \leq d \leq 0.50 \mu\text{m}$.

Claim 16 (Currently Amended): A method for manufacturing a liquid crystal display device having transistors disposed at the intersections of gate lines and source lines, pixel electrodes connected with the transistors, opposite electrodes opposite to these pixel electrodes, and liquid crystal held between said opposite electrodes and said pixel electrodes, wherein said method comprises:

a step for manufacturing a first pixel electrode applying a first electric field to the liquid crystal;

a step for manufacturing an insulating layer in a layer above the first pixel electrode;
a step for manufacturing a second pixel electrode in a layer further above the insulating layer, said second pixel electrode having a region that does not overlap the first pixel electrode, and being electrically connected with the first pixel electrode and applying a second electric field whose strength is different from the first electric field to the liquid crystal; and

a step for applying a first voltage to the first pixel electrode and applying a second voltage to the second pixel electrode, such that a ratio of the first voltage and second voltage is from 0.5:1.0 to 0.9:1.0.

Claim 17 (Currently Amended): A method for manufacturing a liquid crystal display device having transistors disposed at the intersections of gate lines and source lines, pixel electrodes connected with the drain electrodes of the transistors, opposite electrodes opposite to these pixel electrodes, and liquid crystal held between said opposite electrodes and said pixel electrodes, wherein said method comprises:

a step for manufacturing a first pixel electrode electrically connected with said drain electrode and applying a first electric field to the liquid crystal;

a step for manufacturing an insulating layer in a layer above the first pixel electrode;
and

a step for manufacturing a second pixel electrode in a layer further above the insulating layer, said second pixel electrode having a region that does not overlap the first pixel electrode, and being electrically connected with said drain electrode and applying a second electric field whose strength is different from the first electric field applied to the liquid crystal; and

a step for applying a first voltage to the first pixel electrode and applying a second voltage to the second pixel electrode, such that a ratio of the first voltage and second voltage is from 0.5:1.0 to 0.9:1.0.

Claim 18 (Previously Presented): The liquid crystal display device according to Claim 1, wherein the cumulative capacitance for stabilizing the pixel potential during the holding period is formed between said second pixel electrode and a storage capacitance electrode line, and between the second pixel electrode and the preceding gate line adjacent thereto.